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Substitute for form 1449A/B/PTO  <b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>  (Use as many sheets as necessary)				<b>Complete if Known</b>	
				Application Number	Unassigned
				Filing Date	September 11, 2003
				First Named Inventor	Mueller et al.
				Group Art Unit	Unassigned
				Examiner Name	Unassigned
Sheet	1	of	2	Attorney Docket Number	00001CONX224367

U.S. PATENT DOCUMENTS						
Examiner Initials	Doc. No.	U.S. Patent Document		Name of Patentee or Applicant	Date of Publication	Filing Date If Appropriate
		Application or Patent Number	Kind Code			
MG	AA	3,328,141		Lachapelle	June 27, 1967	
MG	AB	3,385,682		Lowen	May 28, 1968	
MG	AC	3,429,080		Lachapelle	Feb. 25, 1969	
MG	AD	3,615,955		Regh et al.	Oct. 26, 1971	
MG	AE	3,887,403		Coggins	June 3, 1975	
MG	AF	3,930,870		Basi	Jan. 6, 1976	
MG	AG	4,169,337		Payne	Oct. 2, 1979	
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MG	AL	4,671,851		Beyer et al.	June 9, 1987	
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MG	AO	5,139,571		Deal et al.	Aug. 18, 1992	
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MG	BA	5,690,807		Clark, Jr. et al.	Nov. 25, 1997	
MG	BB	5,700,383		Feller et al.	Dec. 23, 1997	
MG	BC	5,720,823		Carlson et al.	Feb. 24, 1998	
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MG	BN	6,046,112		Wang	April 4, 2000	
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Yana Guerrero

8-18-04

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Sheet	2	of	2	Attorney Docket Number	00001CONX224367

FOREIGN PATENT DOCUMENTS								
Examiner Initials	Doc. No.	Foreign Patent Document			Name of Patentee or Applicant	Date of Publication	Translation	
		Office	Application or Patent Number	Kind Code			Yes	No**
MG	BS	EP	0 373 501	B1	E.I. DU PONT DE NEMOURS AND COMPANY	March 8, 1995		
MG	BT	EP	0 853 110	A1	TEXAS INSTRUMENTS INCORPORATED	July 15, 1998		
MG	BU	EP	0 853 335	A2	TEXAS INSTRUMENTS INCORPORATED	July 15, 1998		
MG	BV	EP	0 926 715	A2	TEXAS INSTRUMENTS INCORPORATED	June 30, 1999		
MG	BW	WO	97/47030	A1	CABOT CORPORATION	Dec. 11, 1997		
MG	BX	WO	99/62628	A1	ANGUS CHEMICAL COMPANY	Dec. 9, 1999		
MG	BY	WO	00/00560	A1	CABOT CORPORATION	Jan. 6, 2000		

OTHER - NON PATENT LITERATURE DOCUMENTS				
Examiner Initials	Doc. No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number (s), publisher, city and/or country where published.	Translation	
			Yes	No**
MG	BZ	COOK, "Chemical Processes in Glass Polishing," <i>Journal of Non-Crystalline Solids</i> , 120, 152-171 (1990)		
MG	CA	HYASHI et al., "Ammonium-Salt-Added Silica Slurry for the Chemical Mechanical Polishing of the Interlayer Dielectric Film Planarization in ULSI's," <i>Jpn. J. Appl. Phys.</i> , 34 (2B), pt. 1 (1995)		
MG	CB	Angus Chemical Company Technical Data Sheet, DMAMP-80, TDS 18 (1994)		
MG	CC	HOLLAND et al., "Controlling Dielectric Removal Rate and Uniformity in Several New CMP Processes," <i>First International Dielectrics for VLSI/USLI Multilevel Interconnection Conference (DUMIC)</i> , Santa Clara, CA (February 21-22, 1995)		

Examiner Signature		Date Considered	8-18-09
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- \* A concise statement of relevance is being submitted in lieu of a translation. 37 CFR 1.98(a)(3).
- \* An English-language equivalent/patent, or an English-language abstract, or an English-language version of the search report or action by a foreign patent office in a counterpart foreign application indicating the degree of relevance found by the foreign office is being submitted in lieu of a concise explanation of relevance under 37 CFR 1.98(a)(3).